



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **WATANABE, Kenichi**

Serial No.: **09/987,012**

Filed: **November 13, 2001**

Group Art Unit: **2815**

Examiner: **Chris C. Chu**

P.T.O. Confirmation No.: **6363**

For. **SEMICONDUCTOR WAFER DEVICE HAVING SEPARATED CONDUCTIVE PATTERNS IN PERIPHERAL AREA AND ITS MANUFACTURING METHOD**

REQUEST FOR APPROVAL OF DRAWING CHANGES

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

May 15, 2003

Sir:

The Examiner's approval of the drawing corrections indicated in red ink on the attached four (4) sheets of drawings is respectfully requested.

Upon receipt of approval of the drawing corrections and a formal Notice of Allowance, a bonded draftsman will be retained and the appropriate corrections will be made.

In the event any fees are required in connection with this paper, please charge our Deposit Account No. 01-2340.

Respectfully submitted,

ARMSTRONG, WESTERMAN & HATTORI, LLP

James E. Armstrong IV
James E. Armstrong IV
Attorney for Applicant
Reg. No. 42,266

JAM/kas
Atty. Docket No. **011264**
Suite 1000
1725 K Street, N.W.
Washington, D.C. 20006
(202) 659-2930



23850

PATENT TRADEMARK OFFICE

Attachment: 4 Sheets of Corrected Drawings

RECEIVED
MAY 20 2003
TECHNOLOGY CENTER 2000

*disapproved
do not enter
C.C.
7/23/03*

*#9
St to
Patents
J.M. Minnion
5/22/03*